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Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	3237	(356/399-401,614).CCLS.		OFF	2005/12/21 22:07	
L2	6977	(430/5,22,30).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/12/21 22:07
L3	6238	(355/53,55,77).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/12/21 22:07
L4	1196	(250/548).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/12/21 22:08
L5	3144	(438/5,7,14,16).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/12/21 22:09
L6	1984	(1 2 3 4 5) and ((airtight\$4 air vacuum hermetic\$4 pressur\$4) same chamber\$4)	US-PGPUB; USPAT; USOCR	OR	OFF	2005/12/21 22:09
L7	1985	(1 2 3 4 5) and ((airtight\$4 air vacuum hermetic\$4 pressur\$4) same chamber\$4)	US-PGPUB; USPAT; USOCR	OR	ON	2005/12/21 22:12
L8	617	7 and ((position\$3 edge contour) near (measur\$5 sens\$3 detect\$3))	US-PGPUB; USPAT; USOCR	OR	ON	2005/12/21 22:11
L9	220	7 and (((position\$3 edge contour) near (measur\$5 sens\$3 detect\$3)) near (wafer semiconduct\$3 reticle mask photomask substrate))	US-PGPUB; USPAT; USOCR	OR	ON	2005/12/21 22:11
L10	772	((airtight\$4 air vacuum hermetic\$4 pressur\$4) same chamber\$4) and (((position\$3 edge contour) near (measur\$5 sens\$3 detect\$3)) near (wafer semiconduct\$3 reticle mask photomask substrate))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/21 22:12
L11	582	10 and expos\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/21 22:13
L12	327	10 and (expos\$ near (device apparatus system))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/21 22:14

L13	154	12 not 9	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT;	OR	ON	2005/12/21 22:14
1			IBM_TDB			